

Comprehensive Analysis Of Matrix-Type Nanostructured Columnar Composite Coatings Based On Anodic Aluminum And Tantalum Oxides

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Abstract: Matrix-type nanostructured columnar composite coatings based on anodic aluminum oxide (Al_2O_3) and tantalum oxide (Ta_2O_5) represent a promising class of functional materials for advanced surface engineering applications. The anodization process enables the formation of ordered Nano porous and columnar structures with a high specific surface area, which can effectively serve as a matrix for composite oxide systems. In this study, the structural and morphological characteristics of anodic Al_2O_3 - Ta_2O_5 composite coatings are analyzed, with particular emphasis on the formation of matrix-based nanostructured columnar architectures. The article analyzes the micromechanical properties of matrix nanostructures.

Keywords: Aluminum oxide, micromechanical properties, Al alloys, anodization process, tantalum oxide.

INTRODUCTION:

Of particular importance in the fields of modern materials science and surface Engineering is the issue of creating functional coatings. Nanostructured coatings in particular have high mechanical, electrical, and chemical properties and are widely used in the electronics, energy, medical, and aviation industries. In this context, coatings based on aluminium and tantalum oxides produced by the anodizing method are of great scientific and practical interest [1-6].

Anode aluminum oxide (Al_2O_3) and tantalum oxide (Ta_2O_5) are characterized by high dielectric impermeability, chemical stability, corrosion resistance, and heat tolerance properties. In particular, Matrix nanostructured columnar (porist) structures formed during anodizing greatly increase the functionality of the material. node aluminum oxide (Al_2O_3) and tantalum oxide (Ta_2O_5) are characterized by high dielectric impermeability,

chemical stability, corrosion resistance, and heat tolerance properties [7-10]. In particular, Matrix nanostructured columnar (porist) structures formed during anodizing greatly increase the functionality of the material. Such structures have a high specific surface area and act as an effective matrix to create composite coatings.

In Matrix nanostructured columnar Composite coatings, electrical, optical and mechanical properties can be controlled by placing various functional components inside the oxide matrix. And the combined use of aluminum and tantalum oxides makes it possible to increase the reliability, dielectric properties and service life of the composite coating. Such coatings are particularly promising in capacitors, sensors, Microelectronics elements, and biomedical devices [11-13].

At the same time, an in-depth study of the processes

of formation of Matrix nanostructured columnar Composite coatings of anode aluminum and tantalum oxides, determining the relationship between their morphology, structure and functional properties, remains an important scientific task. This article covers the results of research in this particular direction and analyzes the structural and practical properties of the obtained coatings [14].

Experimental Studies

Figure 1 presents electron microscopic images of AAO matrices. In these images, the pores were filled with columns by re-anodization in oxalic acid at applied voltages of 45 V and 450 V [15,16]. All images of the sample can be conventionally divided into approximately four regions: the upper layer of the anodic oxide ($h_{(up)}$), the outer ATO layer ($h_{(low)}$) consisting of nanoscale columns filling the AAO pores, the unanodized tantalum (Ta) film layer, and the silicon substrate.

The thickness-dependence plots correspond to $h_{(up)}$, $h_{(low)}$, and the total thickness of the formed dielectric film, where $h_{(tot)} = h_{(up)} + h_{(low)}$. As can be seen from

Figure 1, metallic tantalum is polycrystalline and is covered with rod-shaped grains formed during magnetron sputtering of the films. The dark band observed at the interface between metallic Ta and AAO is most likely a dense barrier layer.

Oxide columns of different contrast emerge from the dark interfacial line, extend toward the AAO surface, and completely fill the pores. Both the interfacial band and the columns consist of oxide phases, within which a noticeable scattering of electrons is observed, making the columns clearly distinguishable from the AAO matrix. The average diameter of the columns (equivalent circular diameter) was determined to be approximately 50 nm, which is about 2.5 times larger than the average pore size of the corresponding AAO (~20 nm). The results illustrating the relationship between the dimensions of the columnar matrix-type nanostructures and the re-anodization voltages are presented. In addition, the ratio of the initial metal layer thickness required to form fully dense, pore-free structures has been determined.

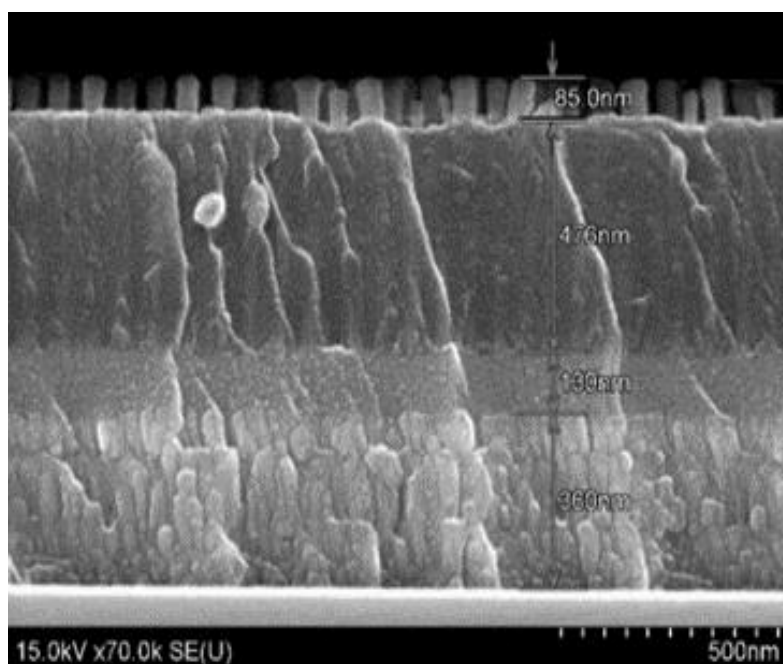


Figure 1. Image of a columnar matrix-type nanostructure formed as a result of anodization of a two-layer Al/Ta system in a 0.2 M oxalic acid solution followed by re-anodization in a 0.5 M boric acid solution.

RESULTS AND DISCUSSION

Figure 2 shows the dependence of the friction force, friction coefficient, and cantilever penetration depth on the applied load in the scratch testing apparatus. The experimental results demonstrate the high mechanical strength of the composite matrix-columnar anodic oxide films. At a maximum load of 50 mN, the penetration depth of a 2 μ m diameter

diamond indenter did not exceed 20% of the 1.5 μ m film thickness after the first pass and 50% after the sixth pass.

A nonlinear dependence of the friction force, friction coefficient, and cantilever penetration depth on the applied load is observed, while the friction coefficient shows only a weak variation at loads up to 20 mN.

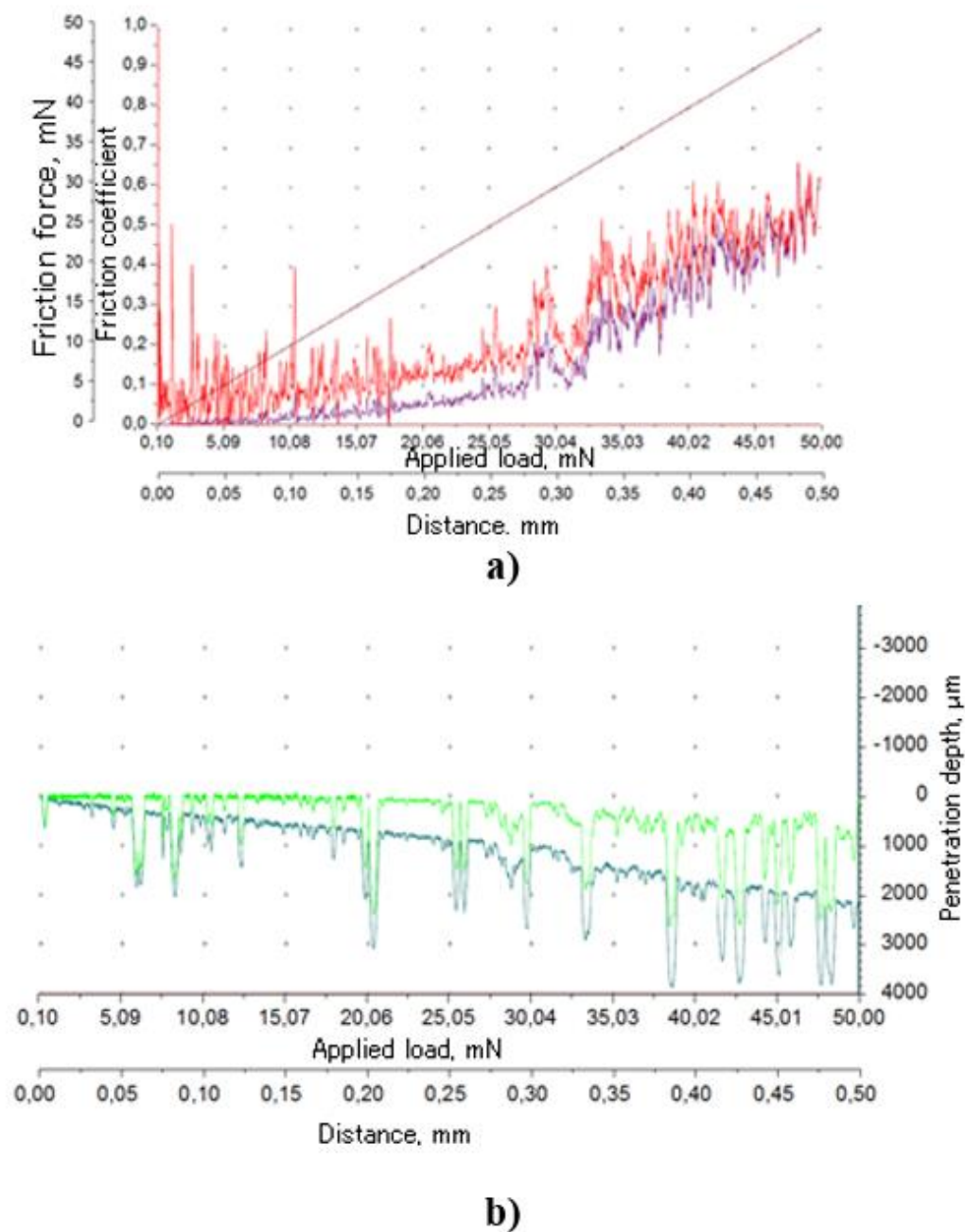


Figure 2. Dependence of the friction force and friction coefficient, as well as the cantilever penetration depth after the sixth pass, on the applied load. (a) Load dependence of the friction force and friction coefficient; (b) Load dependence of the cantilever penetration depth.

Nanoindentation was performed using Berkovich three-sided diamond indenters at maximum loads $P_{\text{max}} = 10, 30, \text{ and } 50 \text{ mN}$. The indentation process involved loading the indenter to P_{max} at a rate of 20 mN/min , holding the maximum load for 30 s , and then unloading. For each P_{max} value, five measurements were carried out on the test sample to

determine the average values of microhardness and elastic modulus. Analysis of the nanoindentation load–displacement curves (Figure 3) was performed according to the Oliver–Pharr methodology. The average values of microhardness and elastic modulus are presented in Table 1

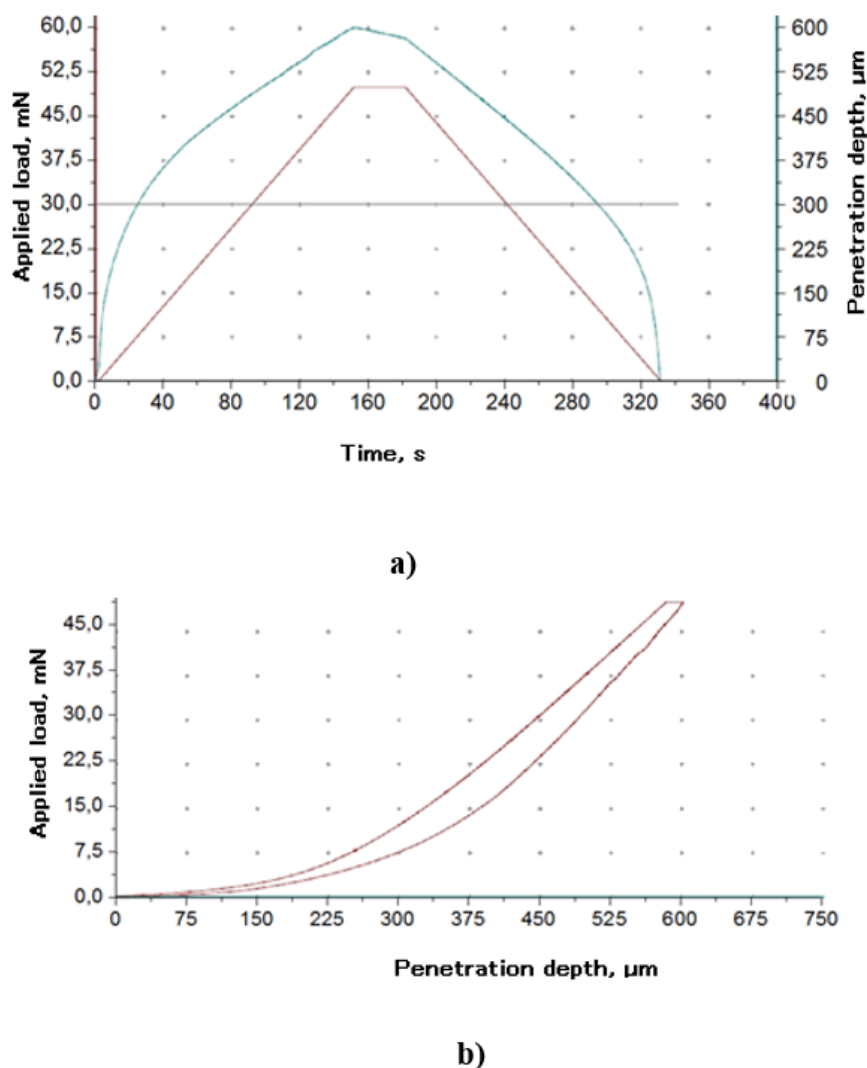


Figure 3. Indentation kinetics and load–displacement (P–h) diagrams of the anodized Ta/Al system. (a) Indentation kinetics;(b) Load–displacement (P–h) diagram.

The obtained results on the micromechanical properties of the matrix-type nanostructures were compared with those of advanced Nano ceramic materials.

Table 1. Micro hardness (H) and elastic modulus (E_p).

| P_{max} | Depth, h | N, MPa | E_p , GPa |
|-----------|----------|--------|-------------|
| 50 mN | 610 nm | 7056.2 | 93.5 |
| 30 mN | 460 nm | 4983.2 | 84.9 |
| 10 mN | 330 nm | 4630.7 | 87.0 |

CONCLUSION

The experimental results presented above indicate that the average values of the elastic modulus and microhardness remain nearly unchanged at applied loads of 10 and 30 mN, whereas a significant increase is observed under an applied load of 50 mN.

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